

<p align="center">NATIONAL PHASE UTILITY APPLICATION</p> <p align="center">Transmittal to the (DO/EO/US) Under 35 USC 371</p>	<p>Attorney Docket No.: SHIGA7.036APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/010270 Int'l Filing Date: July 13, 2004 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232865US</p>
<p>Direct all correspondence to Customer No.: 20995</p> <p align="right">Date: January 12, 2006 Page 1 of 3</p>	

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Yasuo Masuda
2. Toshiki Okui

APPLICATION ELEMENTS:

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
 - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 5 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
 - (X) Listing 15 references.
 - (X) Enclosing 10 references.
- (X) Cover page of PCT publication WO 2005/007719 A3.
- (X) International Search Report and Written Opinion.
- (X) Application Data Sheet in 2 pages.

NATIONAL PHASE UTILITY APPLICATION Transmittal to the (DO/EO/US) Under 35 USC 371	Attorney Docket No.: SHIGA7.036APC First Named Inventor: Masuda, Kenji Int'l Application No.: JP 2004-10270 Int'l Filing Date: July 13, 2004 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232865US
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FILING FEES:

FEE CALCULATION				
FEE TYPE & DETERMINATION		LARGE FEE	CALCULATION	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) (enter one in TOTAL column)				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1640 (\$0)		\$400
(2) USPTO was the ISA (noncompliant claims)		1641 (\$100)		
(3) Foreign Search Report Enclosed		1642 (\$400)		
(4) No Search Report Enclosed		1632 (\$500)		
Examination Fee under 1.492(c) (enter one in TOTAL column)				
(1) USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)		1643 (\$0)		\$200
(2) Non US IPEA or Noncompliant Claims		1633 (\$200)		
Excess Claims	5 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	1 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 =	\$0
Late English Translation		1618 (\$130)		
Assignment		8021 (\$40)	1 x 40 =	\$40
			TOTAL FEE DUE	\$940
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<p>NATIONAL PHASE UTILITY APPLICATION</p> <p>Transmittal to the (DO/EO/US) Under 35 USC 371</p>	<p>Attorney Docket No.: SHIGA7.036APC First Named Inventor: Masuda, Masahito Int'l Application No.: PCT/JP2004/010270 Int'l Filing Date: July 13, 2004 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232865US</p>
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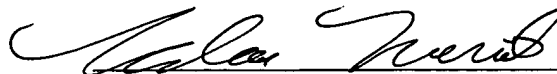
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Attorney Docket No. : SHIGA7.036APC
 Applicant(s) : Masuda et al.
 For : POSITIVE PHOTORESIST COMPOSITION
 AND METHOD OF FORMING RESIST
 PATTERN
 Attorney : Daniel E. Altman
 "Express Mail" Label No. : EV718232865US **EV718232865US**
 Date of Deposit : January 12, 2006

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 49 pages; 1 sheet of drawings; Preliminary Amendment in 5 pages; Application Data Sheet in 2 pages; signed Declaration and Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; International Search Report and Written Opinion; PCT/IB/308; cover page of PCT publication WO 2005/007719 A3; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 10 references; Check for Filing Fee; Return Prepaid Postcard

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